# EXPOSE

### For large PDP masks

## (For image printing exclusive use) Large screen exposure machine

### MODEL SP-2500F

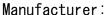
- The exposure machine developed for a large-sized screen plate
- · High transfer accuracy by artificial parallel light system of Fresnel lens
- Illumination unevenness is prevented by a special designed optical processing
- Thereby, high developing work and the stable quality of finished goods are obtained
- Adhesion (Contact) adopted the original sticking-by-pressure system (Cylinder Press Method), and the ideal contact movement to a field from a point has been attained



#### Main specification

Valid size for platemaking	1420 x 1095mm
Maximum Frame Size	2500 x 2500mm
Light source	Instant lighting type metal Halide lamp 6KW (air cooling)
Exposure Light system	Computer control, Maximum of 9ch. (addition actinometer use)
External dimensions	2700(W)x2600(D)x3200(H)mm
Weight	950Kg
Power source	Single-phase 200V 50A
Air Source	Above 5kg/cm(primary measurement)

\* Specifications and design details may be subject to change. C-No.E100802M





for more infomation: